

# Symposium of Metrology 2004



## Second call for papers

October 25-27

Santiago de Querétaro, Qro., México  
Hotel Fiesta Americana

A decade working to strengthen the Mexican Metrology

### Technical sessions:

- Sensors and measurement systems
- Uncertainty evaluation
- Traceability
- Primary standards and high accuracy measurement systems
- New measurement methods
- Reference Materials
- Accreditation of Calibration and Testing Laboratories
- Others

### Additional Information:

**Registration:** Erika Montaño Suárez  
Phone: +52 (442) 211 05 00 al 04, ext. 3013  
Direct: +52 (442) 211 05 83  
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**Chairman:** Roberto Arias Romero  
Phone: +52 (442) 211 05 71

**E-mail:** simposio@cenam.mx

**Web page:** <http://www.cenam.mx>

### Sponsors

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 NATIONAL INSTRUMENTS

## Participation Options

**Author**

**Attendee**

**Sponsor**

### Presentation options

**Oral Session**

**Poster Session**

### Deadlines:

Submission of abstracts: 31st March, 2004

Submission of full papers: 16th June, 2004

### Abstract:

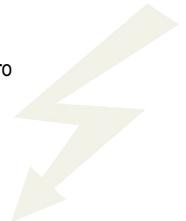
- **Size:** 100 to 200 words
- **Include:** Title of the paper, author's name and affiliation, phone, fax and e-mail details
- **Send it to:** simposio@cenam.mx, or register it at [www.cenam.mx/Simposio2004/Default.asp](http://www.cenam.mx/Simposio2004/Default.asp)

Papers acceptance will be subjected to a Technical Committee evaluation



## Technical Committee

- |   |   |  |
|---|---|--|
| <ul style="list-style-type: none"> <li>• Alicia Pons Aglio<br/>IFA - CSIC / Spain</li> <li>• Arturo Orozco Santillán<br/>CCADET - UNAM</li> <li>• Benjamín Arroyo Ramírez<br/>Instituto Tecnológico de Celaya</li> <li>• Daniel Slomovitz<br/>UTE / Uruguay</li> <li>• David Ríos Jara<br/>CIMAV</li> <li>• Edgar Méndez Lango<br/>CENAM</li> <li>• Eduardo Castillo Castañeda<br/>Universidad Autónoma de Querétaro</li> <li>• Eduardo Tepichín Rodríguez<br/>INAOE</li> <li>• Elisa Felicitas Arias<br/>BIPM</li> <li>• Enrique Fernández Fassnacht<br/>Sub-Secretaría de Educación Superior e<br/>Investigación Científica (SESIC)</li> <li>• Enrique Villa Diharce<br/>CIMAT</li> <li>• Eugen Trapet<br/>UNIMETRIK S.A. / Spain</li> <li>• Felipe Hernández Márquez<br/>CENAM</li> <li>• Fernando Mendoza Santoyo<br/>CIO</li> <li>• Fernando Motolinía Velázquez<br/>CIDESI</li> <li>• Florencio Sánchez Silva<br/>ESIME - Instituto Politécnico Nacional</li> <li>• Gerardo Ruiz Botello<br/>CCADET - UNAM</li> </ul> | <ul style="list-style-type: none"> <li>• Giorgio Moscati<br/>Instituto de Física - USP / Brazil</li> <li>• Gregory Kyriazis<br/>INMETRO / Brazil</li> <li>• Héctor Laiz<br/>INTI / Argentina</li> <li>• Humberto Gómez Ruiz<br/>Facultad de Química - UNAM</li> <li>• Ignacio Hernández Gutiérrez<br/>CENAM</li> <li>• Isaías Regalado Contreras<br/>CIATEQ</li> <li>• Joaquín Valdés<br/>INTI / Argentina</li> <li>• Jorge Cogno<br/>INTI / Argentina</li> <li>• José Luis Jurado Baizaval<br/>CIDETEC</li> <li>• José Ramón Zeleny Vázquez<br/>Mitutoyo Mexicana, S.A. de C.V.</li> <li>• Josefina de Gyves Marciñiak<br/>UNAM</li> <li>• Juan Angel Forastieri<br/>INTI / Argentina</li> <li>• Juan Ignacio Ustarán Cervantes<br/>Laboratorio ABC Química, Investigación y<br/>Análisis, S.A. de C.V.</li> <li>• Kazuto Kawakita<br/>IPT / Brazil</li> <li>• Luis Efraín Regalado<br/>Universidad de Sonora</li> <li>• Luis Omar Becerra Santiago<br/>CENAM</li> <li>• Luciana Scarioni Dallagata<br/>FACYT / Venezuela</li> </ul> | <ul style="list-style-type: none"> <li>• Máximo Cargnelutti<br/>ITESM - Campus Querétaro.</li> <li>• Máximo López López<br/>CINVESTAV - IPN</li> <li>• Miguel Tufiño Velázquez<br/>Instituto Politécnico Nacional</li> <li>• Miguel Viliesid Alonso<br/>CENAM</li> <li>• Oscar Olvera Silva<br/>ITESM - Campus Querétaro</li> <li>• Pablo Canalejo Cabrera<br/>IBSEI</li> <li>• Paulo Couto<br/>INMETRO / Brazil</li> <li>• Pedro Morales Puente<br/>Instituto de Geología - UNAM</li> <li>• René D. Carranza López Padilla<br/>CENAM</li> <li>• Salvador Echeverría Villagómez<br/>CENAM</li> <li>• Saúl López Silva<br/>Universidad Autónoma de Guerrero</li> <li>• Sergio López Carmona<br/>Agilent Technologies México</li> <li>• Víctor Luis Fajer Ávila<br/>CEADEN / Cuba</li> <li>• Víctor Manuel Castaño<br/>Centro de Física Aplicada y Tecnología<br/>Avanzada - UNAM</li> <li>• Walter Bich<br/>IMGC / Italy</li> <li>• Yoshito Mitani Nakanishi<br/>CENAM</li> </ul> |
|---|---|--|



## Organizing Committee

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Roberto Arias Romero  
Phone: +52 (442) 211 05 71

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+52 (442) 215 3904

## Preliminary Program

### Plenary sessions

- A decade of work to strengthen the Mexican Metrology  
*Dr. Héctor Nava Jaimes / General Director, Centro Nacional de Metrología (CENAM/Mexico)*
- The impact of metrology for the economic and social development  
*Dr. Arden Bement / Director, National Institute of Standards and Technology (NIST/USA)*
- Traceability of measurement results in industrial metrology  
*Prof Dr Michael Kuehne / Member of the Presidential Board of the Physikalisch Technische Bundesanstalt (PTB/Germany)*
- The importance of thermo physical properties of materials for industrial development  
*Dr. Akira Ono / Director, National Measurement Institute of Japan (NMJJ/Japan)*



### Round tables

- Challenges and opportunities of development for the Mexican Metrology Community
- Evolving needs for metrology in trade, industry and society, and the role of the NMIs
- Perspectives of metrological development within CENAM

### Oral parallel sessions

### Poster session

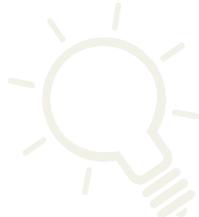
### Exhibition

## Recovery Fee

### Authors and attendees:

**US \$ 425**

Fee includes proceedings, certificate of attendance, 3 lunches, coffee breaks and one Banquet ticket



### Sponsors:

**US \$ 1800**

Space for exhibition of equipment

**US \$ 720**

Space for exhibition of commercial poster

Fee includes certificate of attendance, proceedings, 3 lunches, coffee breaks and one Banquet ticket (all for one person), and the inclusion of company logo on promotion material.

**US \$ 220**

for additional person (two additional at maximum)

### Students:

**US \$ 160**

Fee includes: certificate of attendance, proceedings, 3 lunches, coffee breaks and one Banquet ticket

**Fees are valid until July 31, 2004**

## Payments

- **Cash**
- **Money transfer**

Our bank details will be provided opportunely.



## List of topics

- |  |  |  |
|--|--|--|
| 1) Electromagnetic measurements<br>a) DC voltage and current<br>b) Low frequency measurements<br>c) Radiofrequency and Microwaves<br>d) Magnetism  | 8) Force and Pressure<br>a) Force and Torque<br>b) Pressure and Vacuum<br>c) Hardness and Toughness                              | e) Raw materials<br>f) Metallurgy<br>g) Gas mixtures<br>h) Agriculture |
| 2) Time and frequency  | 9) Mass and density<br>a) Mass<br>b) Density   | 15) Uncertainty in Measurements  |
| 3) Temperature and Humidity<br>a) Contact thermometry<br>b) Pyrometry<br>c) Humidity<br>d) Thermal conductivity and heat transfer  | 10) Volume and Flow<br>a) Liquid flow-rate<br>b) Gas flow-rate<br>c) Calibration of glassware<br>d) Calibration of large vessels | 16) Statistic Process Control  |
| 4) Optics and Radiometry<br>a) Radiometry: detectors and sources<br>b) Photometry<br>c) Characterization of optical properties:<br>Spectrophotometry, colour, polarimetry, etc.<br>d) Fibre optics and optoelectronics<br>e) Holographic methods | 11) Viscosity and Rheology   | 17) Validation of methods  |
| 5) Ionizing radiation  | 12) Metrology in Chemistry<br>a) Primary methods<br>b) Gas metrology<br>c) Purity measurements                                   | 18) Quality Systems  |
| 6) Acoustic and vibration<br>a) Acoustics<br>b) Vibration  | 13) Reference Materials<br>a) Solutions<br>b) Simple matrix<br>c) Complex matrix<br>d) Development of reference materials        | 19) Standardization  |
| 7) Dimensional Measurements<br>a) Primary standards and interferometry<br>b) Length and shape<br>c) Gage blocks, angle, roundness, etc.<br>d) Coordinate Measuring Machines<br>e) Roughness  | 14) Reference Materials applications<br>a) Food<br>b) Biometrology<br>c) Environment<br>d) Geochemistry and others               | 20) Accreditation  |
|  |  | 21) Comparison and Proficiency testing                                 |
|  |  | 22) Automation of Measuring Systems                                    |
|  |  | 23) Image processing   |
|  |  | 24) Legal Metrology and pattern approval of<br>Measuring instruments   |
|  |  | 25) Training in Metrology  |
|  |  | 26) General Topics in Metrology  |



## Pre-registration form symposium of metrology 2004

**Send to:** Erika Montaño Suárez / Organizing Committee - Registration  
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**Direct:** +52 (442) 211 05 83  
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### I wish to participate as:

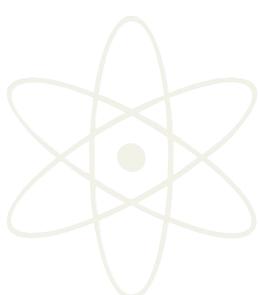
- Attendee  
 Author  
 Oral presentation  
 Poster

Topic: \_\_\_\_\_

Classification No.

See page 4 for classification scheme

Please attach copy of the abstract(oral presentation or poster)



- Sponsor  
 With space for exhibition  
 With space for poster

### My personal details are:

Name: \_\_\_\_\_

Company/Organization: \_\_\_\_\_

Address: \_\_\_\_\_

Zip/post code and city: \_\_\_\_\_ Country: \_\_\_\_\_

Telephone and Fax: \_\_\_\_\_ E-mail: \_\_\_\_\_

*At your convenience, you will be informed on the procedures to complete your registration.*